



#3/5/27/03  
Drugs.

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re U.S. Patent Application of: ) Attorney Docket: 4425-168  
)  
Yen-Ting Lu ) Group Art Unit: 1756  
)  
Serial No.: 09/919,868 ) Examiner: C. G. Young  
)  
Filed: August 2, 2001 )

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TC 1700

For: METHOD FOR REDUCING LINE EDGE  
ROUGHNESS OF PHOTORESIST

**REQUEST FOR APPROVAL OF DRAWING AMENDMENT**

Honorable Commissioner for Patents  
Washington, D.C. 20231

Sir:

Approval of the revisions to Figures 3A-3C, as shown in red ink on the  
attached photocopies, is respectfully solicited.

Respectfully submitted,

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Date: May 21, 2003  
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May 21, 2003  
  
Jane Katsarelis

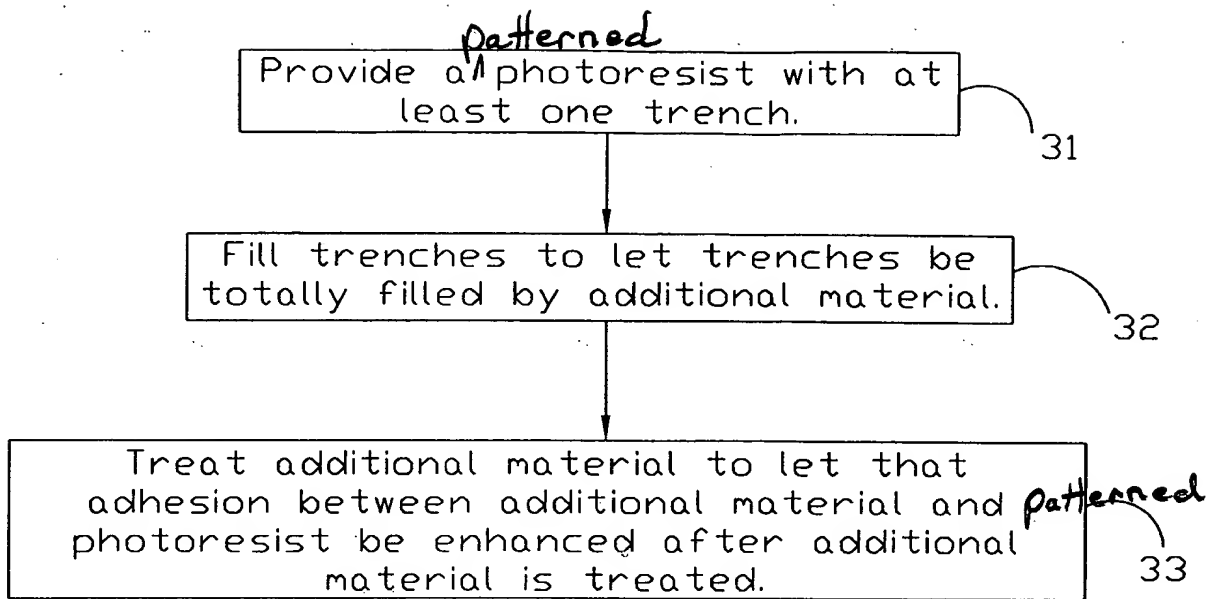
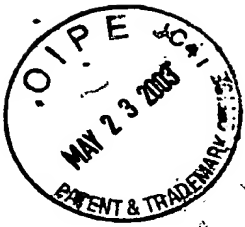


FIG.3A

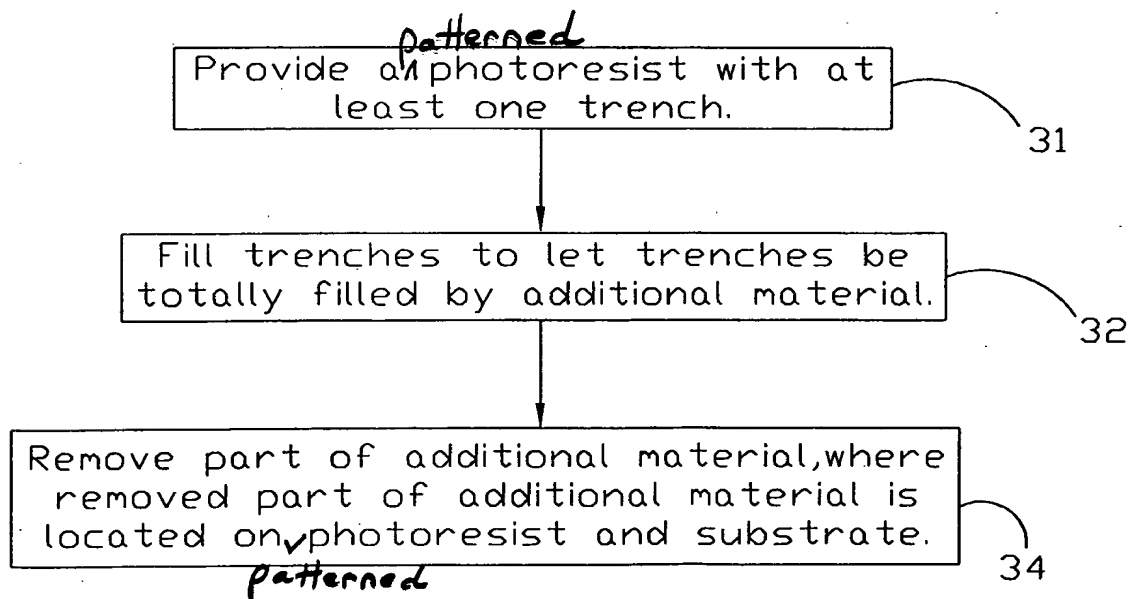


FIG.3B

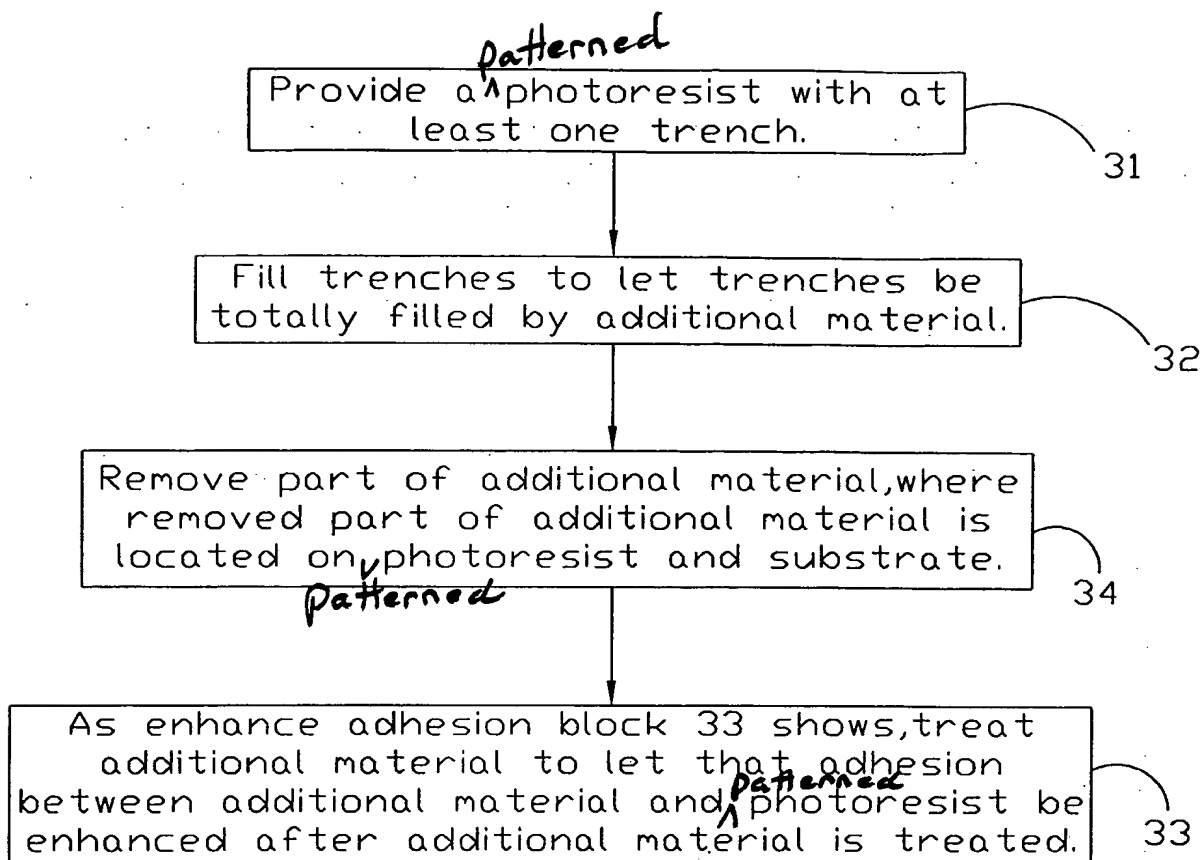
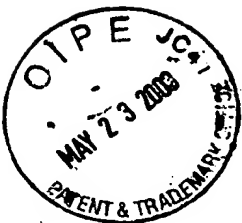


FIG.3C